

# Thin-film ferroelectric oxides for photovoltaic energy production



Stands For Opportunity

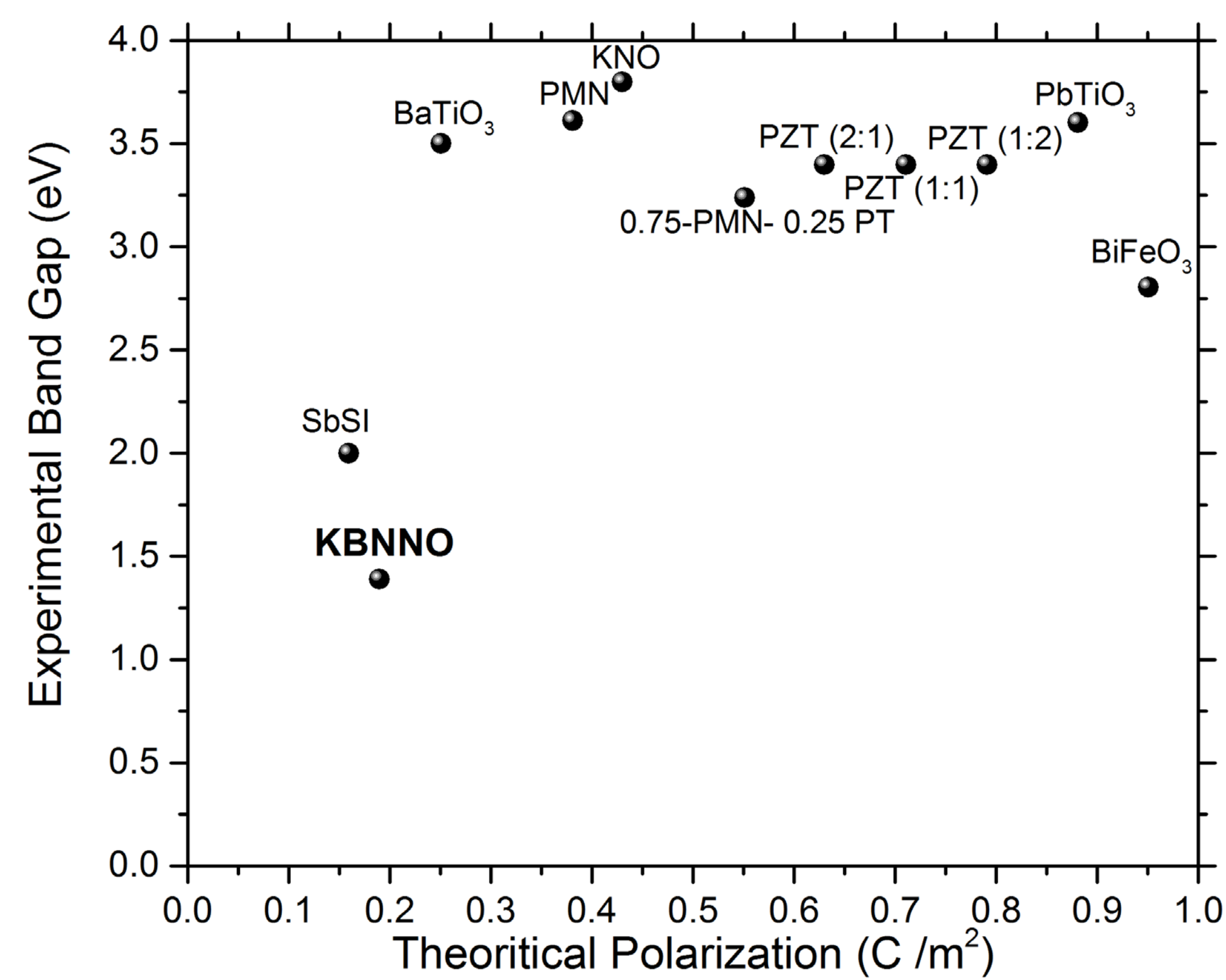
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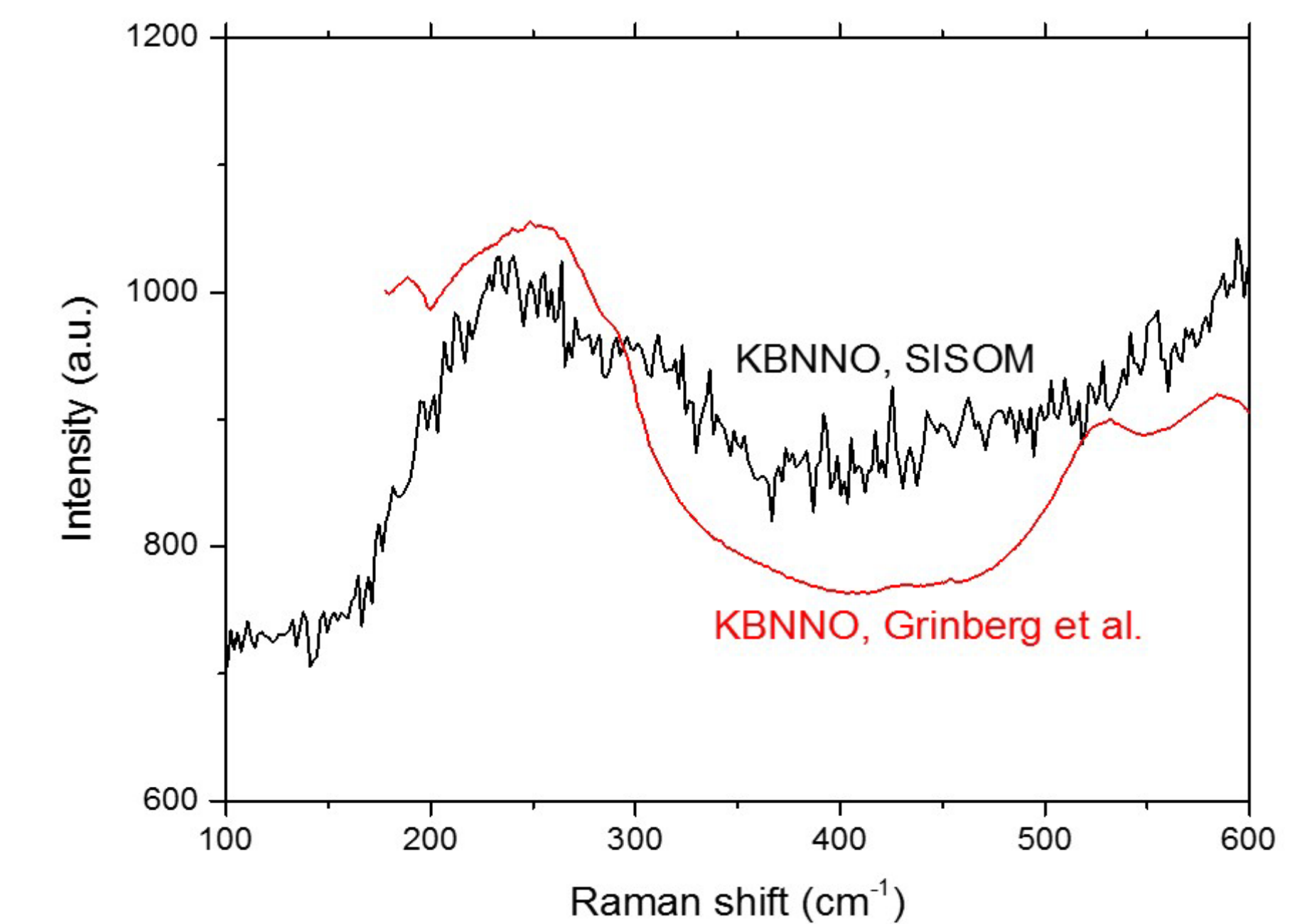
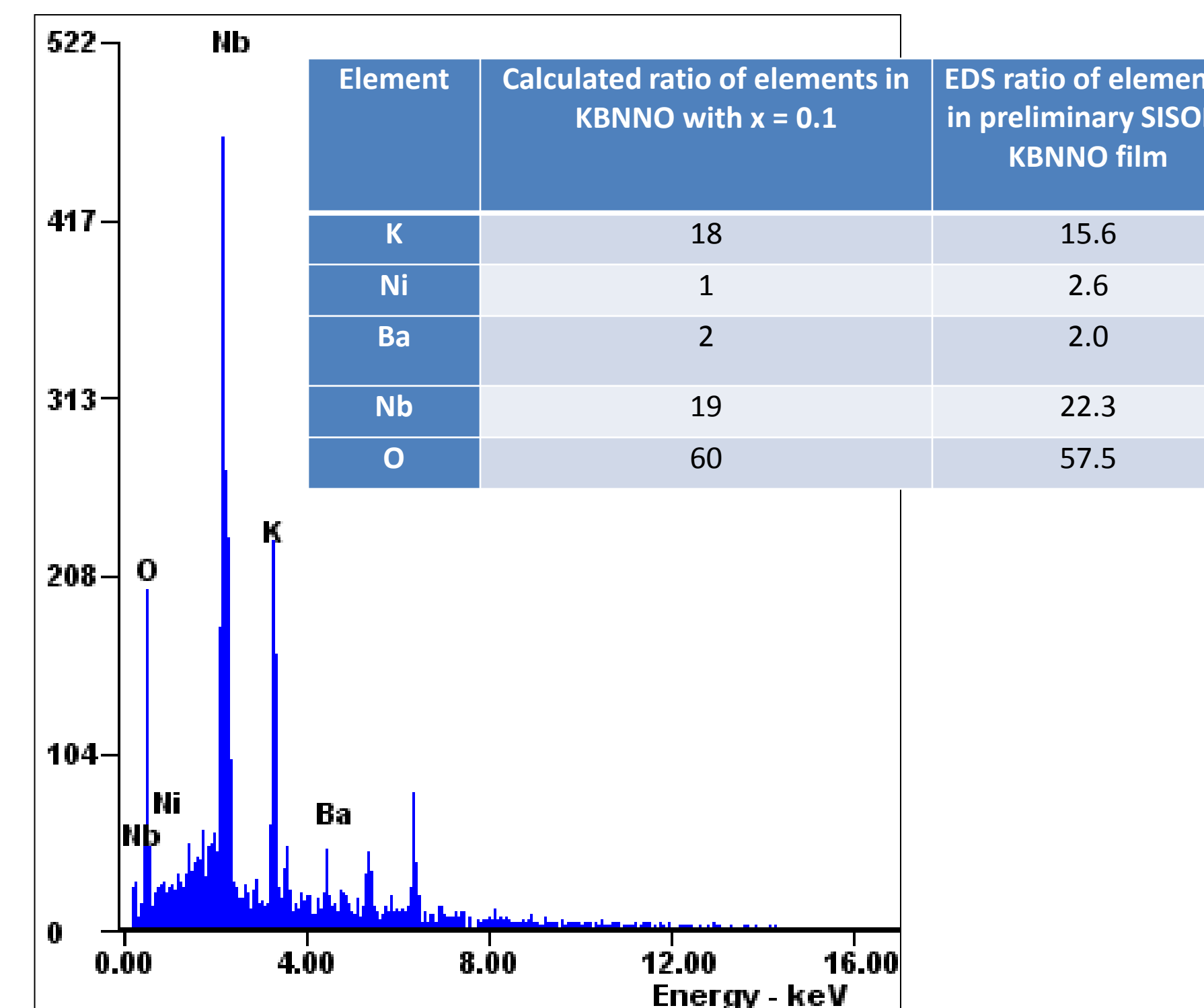
<sup>2</sup>SISOM thin films LLC., Orlando, FL 32805, USA

SISOM THIN FILMS

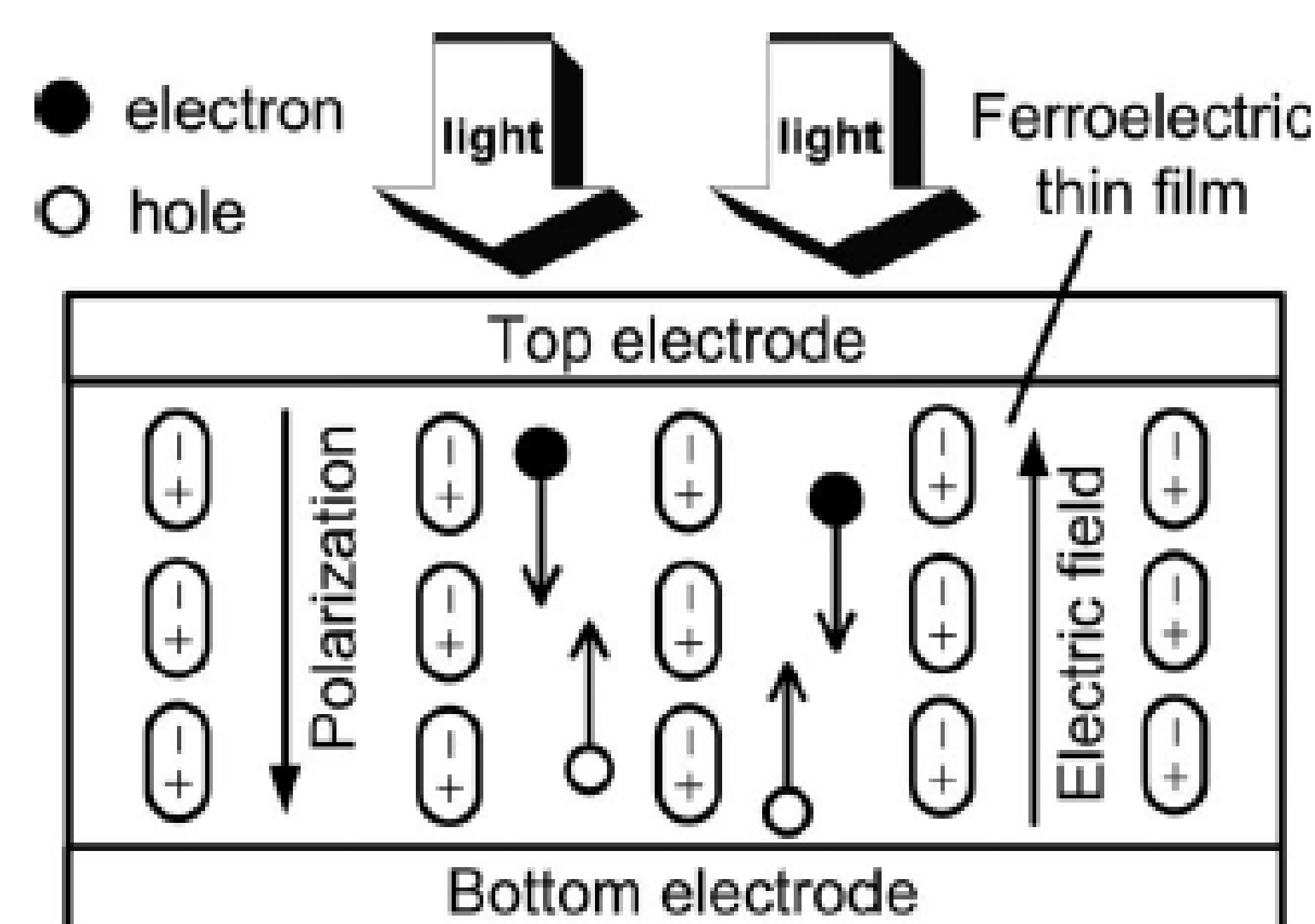
The new ferroelectric oxide  $[\text{KNbO}_3]_{1-x}[\text{BaNi}_{1/2}\text{Nb}_{1/2}\text{O}_{3-\delta}]_x$  or “KBNNO” offers potential for unprecedented solar cell efficiency. Usual ferroelectric photovoltaics have been uncompetitive due to large band gaps, which poorly absorb the solar spectrum, while KBNNO features an alloy-tunable band gap as low as 1.1 eV, so that its absorption can be tailored to match the solar spectrum.



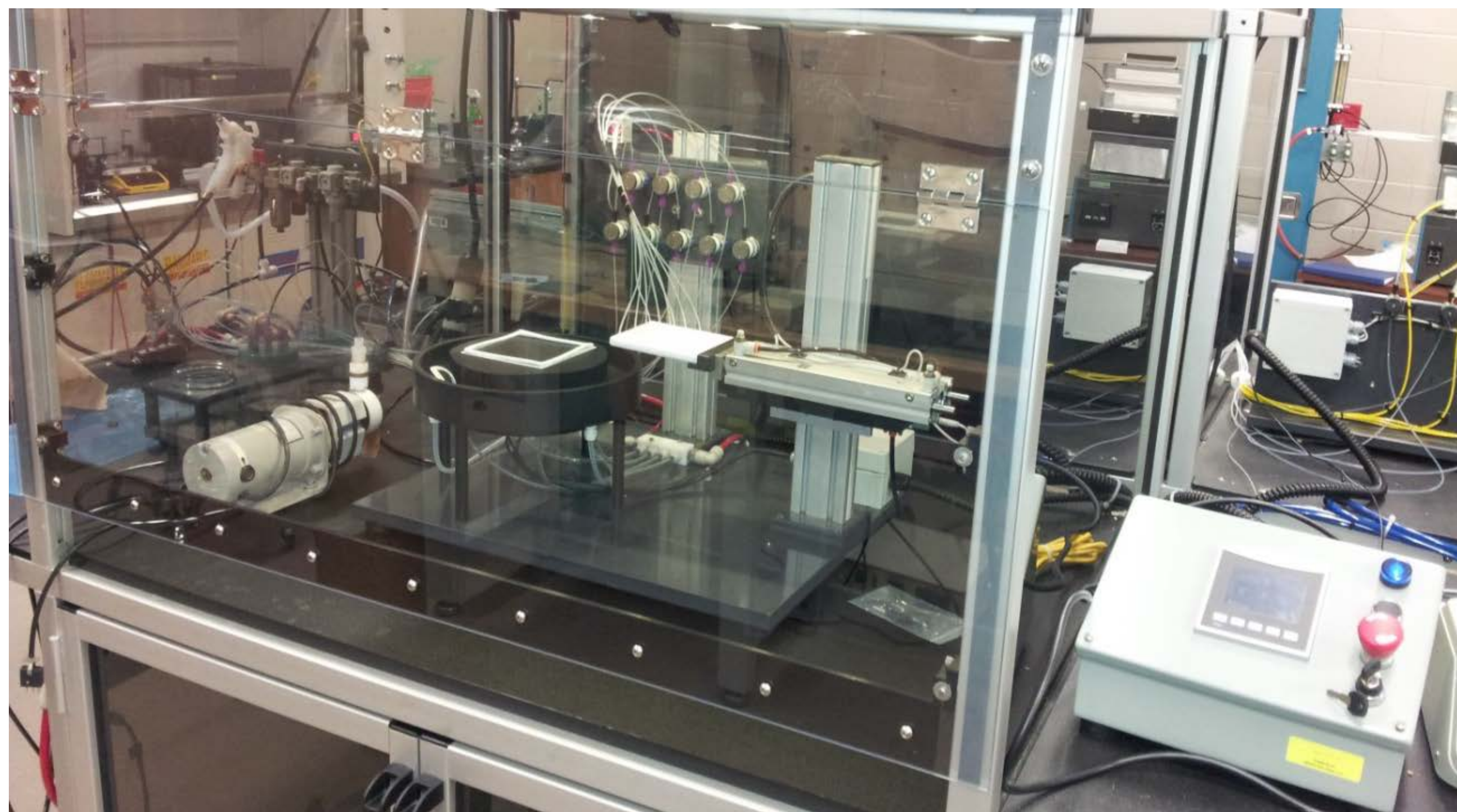
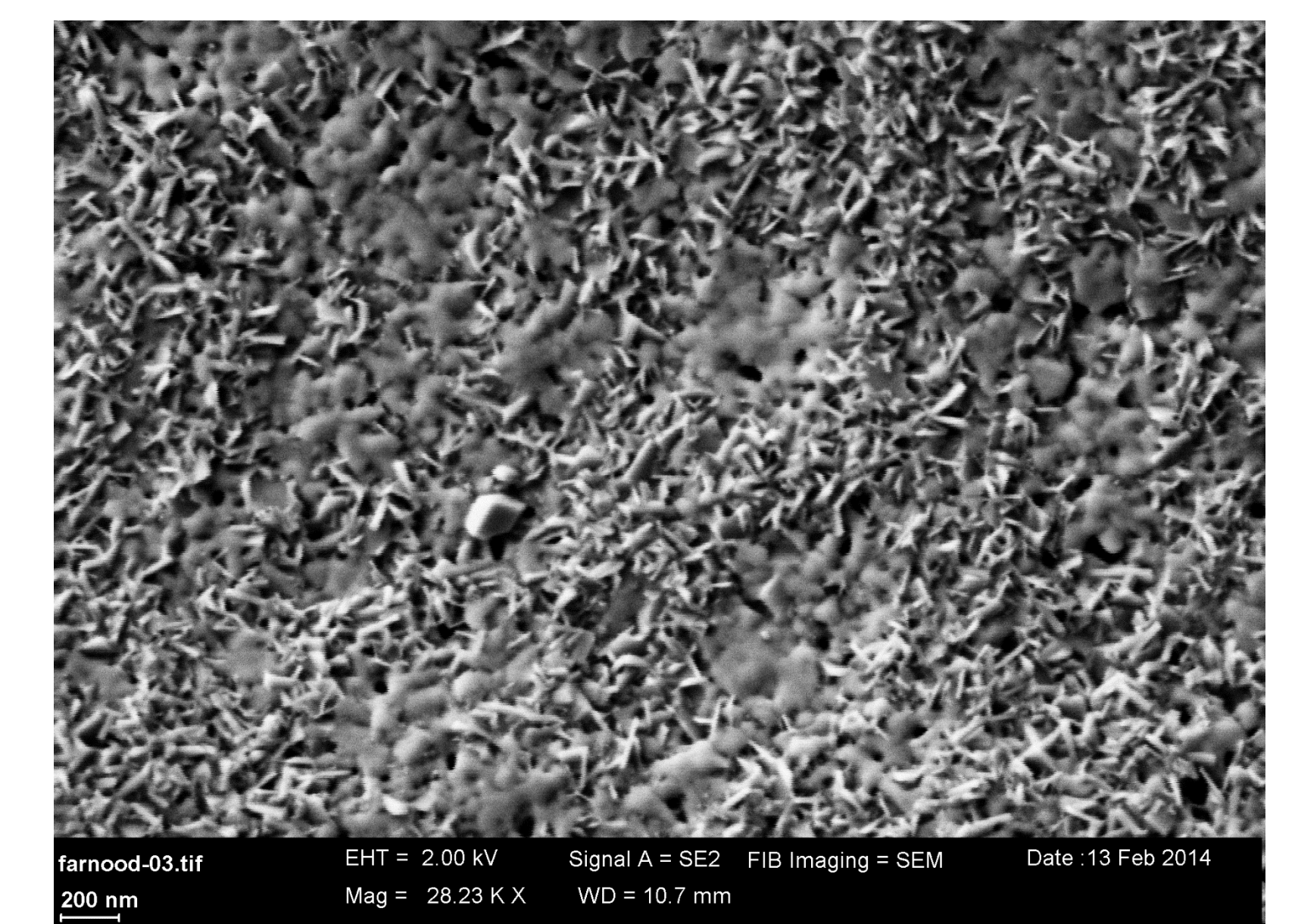
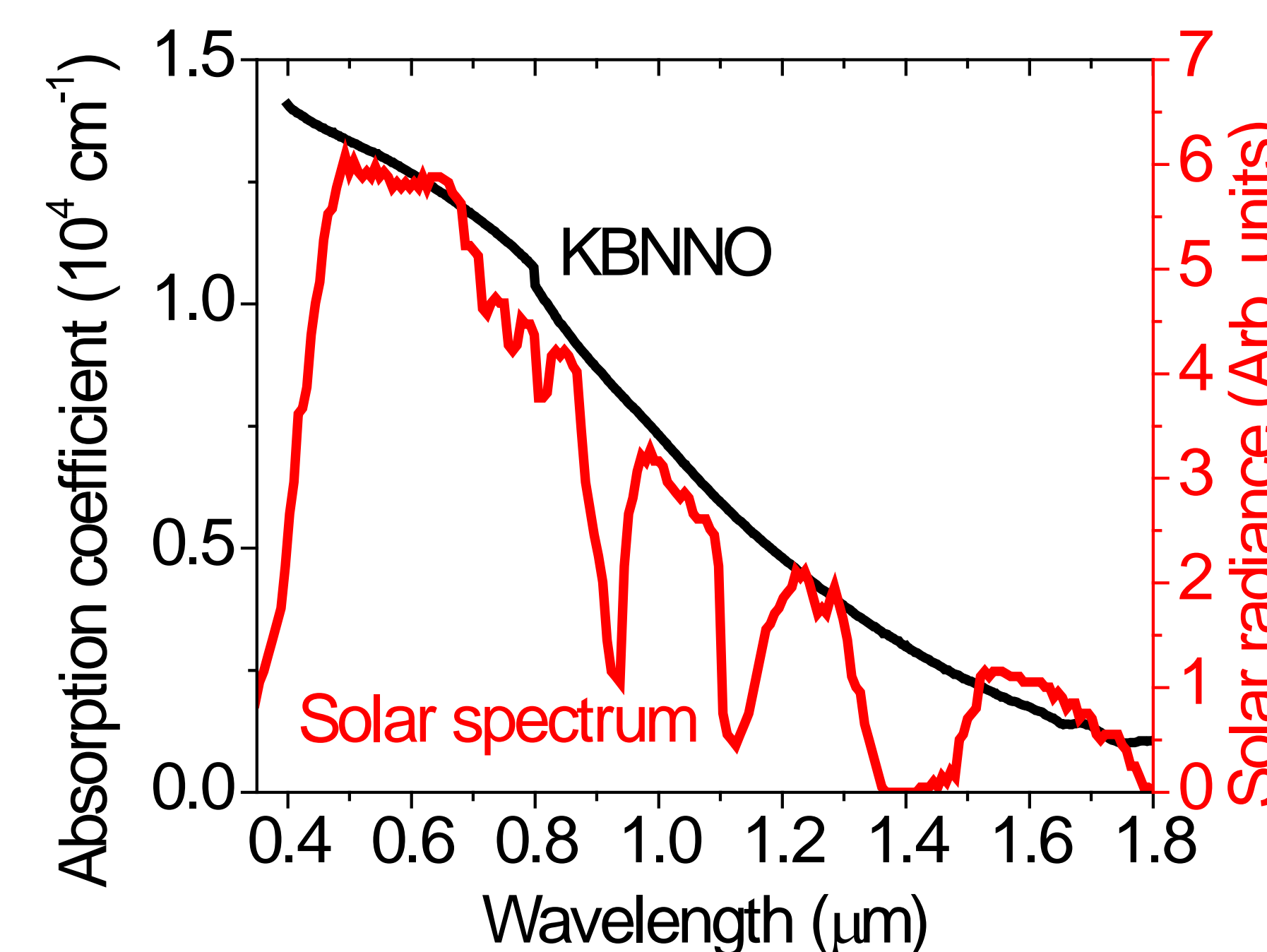
The correct concentrations of Nb, K, Ni, Ba, and O in the grown films was confirmed by Energy Dispersive Spectroscopy (EDS), and the Raman spectrum agrees with literature results for sintered KBNNO.



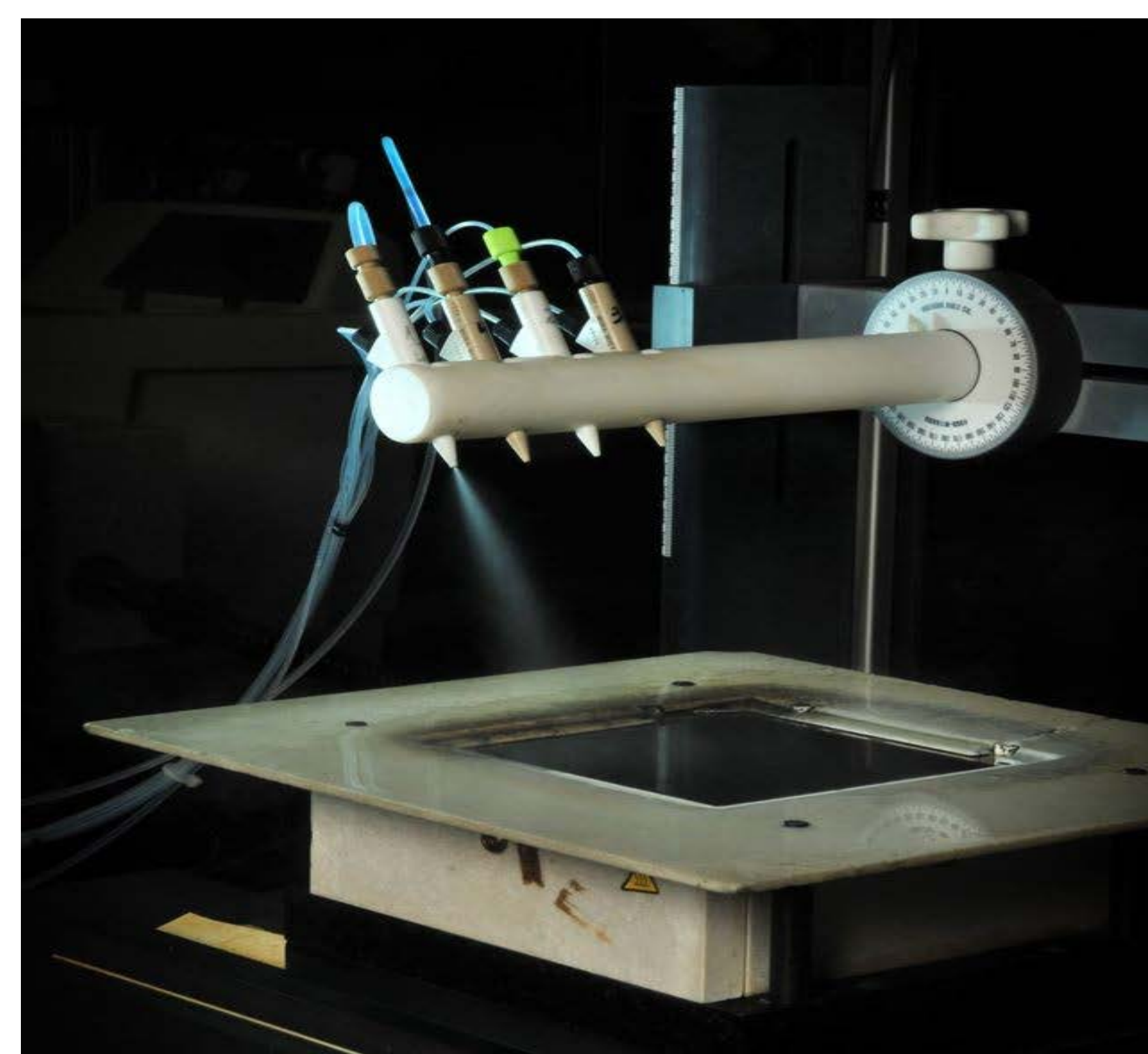
Ferroelectrics have recently attracted attention [1] due to their spontaneous polarization  $P$ , which provides Bulk Photovoltaic Effect (BPVE), where a bulk electric field separates photogenerated charge carriers. KBNNO has a reasonably large polarization allowing for charge separation across the bulk. Open-circuit voltages  $V_{oc}$  exceed the band gap, potentially leading to efficiencies that exceed those possible for standard pn-junction cells if the current collection can be improved using suitable contacts.



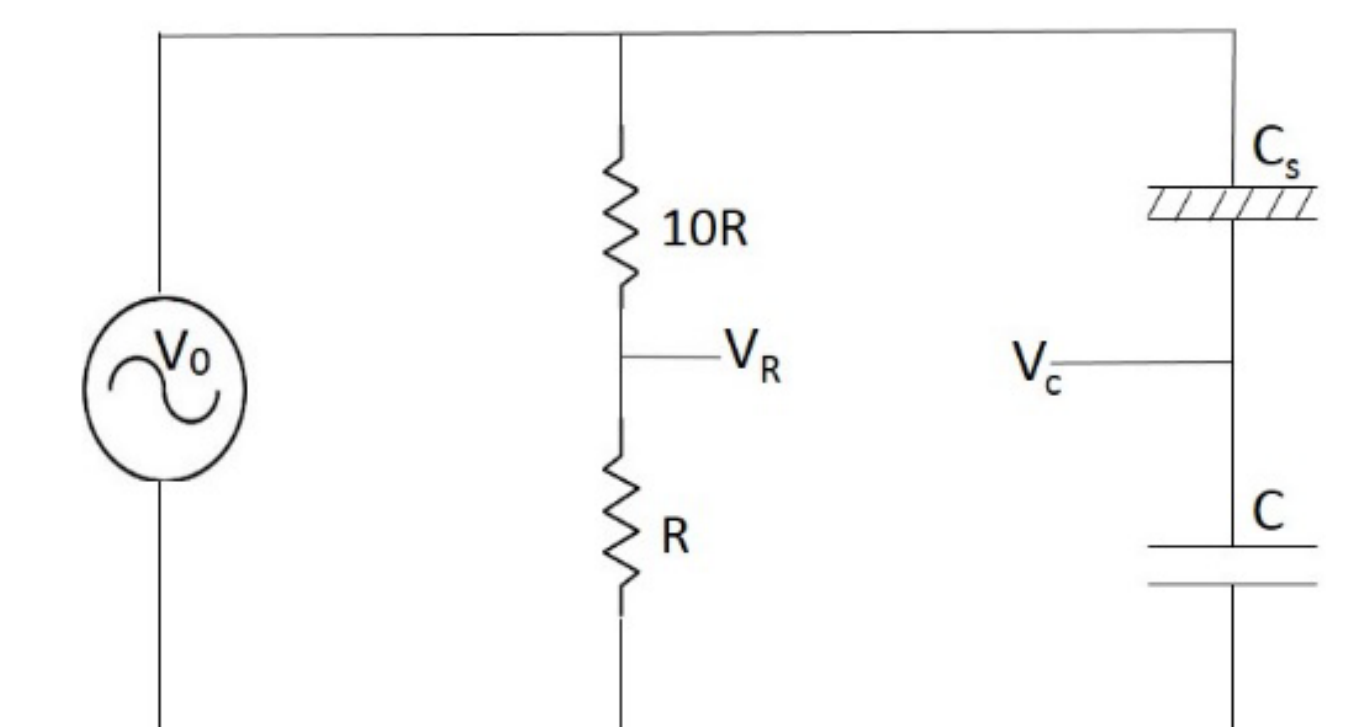
The optical absorption spectrum of the KBNNO film matches the solar emission spectrum. Film thickness of just  $\sim 1 \mu\text{m}$  suffices to absorb most of the light.



KBNNO films are grown by SISOM's innovative aqueous chemical spray method on hydrophilic substrates, known as SPEED. Hydrophilic substrates attach hydroxyl ions ( $\text{OH}^-$ ) from the precursor solution in a high-density monolayer ( $>10^{12}$  sites/ $\text{cm}^2$ ), forming reaction nucleation sites. Heterogeneous reactions form the desired molecules if the substrate temperature supplies at least the activation energy of reaction, usually in the range 125 – 300 C. The films consist of densely packed 50-100 nm grains. Recrystallization is accomplished by post-growth annealing at 400 – 700 C.



Ferroelectric hysteresis (Polarization  $P$  vs. electric field  $E$ ) is measured by the Sawyer-Tower method.



Characterization of the photovoltaic IV curve will be measured using a filtered Xenon arc lamp



## References

- [1] I. Grinberg, D. Vincent West, M. Torres, G. Gou, D. M. Stein, L. Wu, G. Chen, E. M. Gallo, A. R. Akbashev, P. K. Davies, J. E. Spanier & A. M. Rappe, “Perovskite oxides for visible-light-absorbing ferroelectric and photovoltaic material”, Nature 503 (2013).
- [2] M. Qin, K. Yao, Y. C. Liang, “High efficient photovoltaics in nanoscaled ferroelectric thin films”, Appl. Phys. Lett. 93, 12290 (2008)
- [3] J. Bennett, I. Grinberg and A. Rappe, “New highly polar semiconductor ferroelectrics through  $d^8$  cation-O vacancy substitution into  $\text{PbTiO}_3$ : A theoretical study”, J. Am. Chem. Soc. 130, 17409 (2008).

